

What is claimed is:

1. A double sided electrical interconnection flexible  
5 circuit, to enable interconnecting an integrated circuit chip to an external circuit, including:

a base dielectric film of a flexible polymeric material,

10 a conductor pattern on the first surface of dielectric film having a plurality of contact pads for interconnection from the chip terminals, interconnection between said pads, and from said pads to conductive vias through the film,

15 a plurality of solder ball contact pads on the second surface of the dielectric film patterned from an etched metal film matrix, and

a plurality of conductive vias ~~comprising~~ metal studs etched from said metal matrix, which interconnect the conductors on the first surface to those on the second surface of said dielectric film.

20 2. The flexible circuit as described in claim 1 in wherein the metal matrix with etched studs comprise copper.

3. The flexible circuit as described in claim 1 wherein the etched studs everted from the metal matrix constitute a tool for punching a pattern of apertures corresponding to  
25 conductive vias in the dielectric film.

4. The flexible circuit as described in claim 1 which provides the interconnection circuitry for the substrate of an area array integrated circuit package.

5. The flexible circuit as described in claim 1 further  
30 including a plated copper layer disposed over the interconnect patterns and solder ball contact pads.

6. A flexible circuit as described in claim 5 which further including a plated layer of nickel and of gold over the conductor patterns and solder ball contact pads.

7. A flexible circuit as described in claim 1 further  
5 including a plurality of openings parallel to the film edges  
which correspond to a sprocket transport mechanism.

8. A flexible circuit as described in claim 1 wherein said base dielectric film comprises a polyimide polymer in the range of 0.003 to 0.006 inches thick.

2 10 9. A double sided electrical interconnection flexible circuit substrate for an area array integrated circuit package to enable interconnecting an integrated circuit chip to an external circuit including :

a base dielectric film of a flexible polymeric material  
15 in the range of 0.003 to 0.006 inches thick,

a conductor pattern comprising copper on the first surface of dielectric film having a plurality of contact pads for interconnection from the chip terminals, interconnection between said pads, and from said pads to

20 conductive vias through the film,

a plurality of solder ball contact pads on the second surface of the dielectric film patterned from an etched metal matrix,

a plurality of solid conductive vias filled with metal studs comprising copper, etched from said metal matrix which interconnect the conductors on the first surface to those on the second surface of said dielectric film, and which constitute a tool for punching apertures in a pattern of conductive vias, and

30 a layer of plated copper disposed over said  
interconnect patterns and solder ball contacts, and a layer  
of nickel and gold over the plated copper.



b. applying a force to said metal matrix so that the studs of the tool punch through the copper coated polymer film, thereby creating a plurality of vias filled with the studs, and attaching the film matrix to the second side of the flex film,

c. electroplating a thin film of copper onto both sides of the copper clad flex film.

17. A die plate mechanism, to facilitate punching apertures in a flex circuit film using studs etched from a metal matrix, including a relatively thin metal plate in the range of 0.004 to 0.010 inches thick having apertures precisely matched to said studs, and a relatively thick plate having larger apertures.

18. A method of manufacturing a flex circuit on a flexible base polymer including the steps of:

a. superimposing an embossing tool having a pattern of conductors and vias corresponding to a circuit design, wherein said raised areas are coated with a thin layer of metal, comprising copper,

b. applying heat and pressure to simultaneously emboss the film and to transfer said thin metal layer from the embossing tool to the dielectric film,

b. removing the embossing tool,

c. embossing a pattern corresponding to that of the second surface of a flex circuit, and simultaneously transferring a thin layer of metal into the embossed pattern,

d. physically removing the embossing tool,

e. plating a layer of copper to fill the vias and conductor patterns on both sides of the film, and

f. plating a layer of nickel and gold onto the exposed copper patterns.

g. applying a solder mask on the surface of the film surrounding the solder ball contact pads.

19. A method of making an embossing tool as in claim 18 wherein a thin layer of loosely held copper is selectively coated onto the raised areas of said tool by treating the raised areas with a thermoplastic adhesive and exposing to a suspension of copper powder.

20. An embossing tool, as in claim 18 wherein a thin layer of loosely held copper is selectively plated onto the raised areas of said tool.

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